

## Conductive Oxide with Surface Polarity for Device Applications

A layered delafossite, PdCoO<sub>2</sub>, is one of the most conductive oxides with a bulk conductivity comparable with those of Au metals. Charged layers of Pd<sup>+</sup> and [CoO<sub>2</sub>]<sup>-</sup> alternate in the PdCoO<sub>2</sub> crystal structure, generating surface polarities that strongly influence the surface/interface properties. Using pulsed laser deposition, we successfully grew high-quality thin films of PdCoO<sub>2</sub> and fabricated functional devices: a nanodevice showing quantum transport and a diode that can operate at elevated temperatures. The superior properties of these devices are attributed to the anisotropic electrical conductivity of PdCoO<sub>2</sub> that originates from its unique layered crystal structure.

The layered oxide PdCoO<sub>2</sub> has attracted significant attention as a highly conductive metal comparable to the noble metals (Fig. 1). Using PdCoO<sub>2</sub> thin films [1], we are currently exploring novel electronic functionalities that originate from two key features of PdCoO<sub>2</sub>: the high electron mobility (~51000 cm<sup>2</sup>/Vs for bulk single crystals) and surface polarity induced by the ionic layered structure (inset of Fig. 1). By fabricating submicron-scale Hall-bar devices using electron beam lithography, we carried out the first observation of quantum transport in PdCoO<sub>2</sub> thin films [2]. We found that the surface polarity of PdCoO<sub>2</sub> significantly affects the surface electronic states, giving the inherently nonmagnetic PdCoO<sub>2</sub> unique magnetic states in the vicinity of the Pd-terminated surfaces [3]. The interplay between surface magnetic states and quantum effects would be an interesting subject for future study.

The surface polarity of PdCoO<sub>2</sub> can improve the performance of practical and useful devices. We fabricated a crystalline heterointerface of PdCoO<sub>2</sub> and a wide-bandgap semiconductor β-Ga<sub>2</sub>O<sub>3</sub>. We found that the PdCoO<sub>2</sub>/β-Ga<sub>2</sub>O<sub>3</sub> interface can function as a Schottky diode that performs current rectification even at a high temperature of 350 °C [4]. The PdCoO<sub>2</sub>/β-Ga<sub>2</sub>O<sub>3</sub> diode can operate in the MHz frequency, which shows promise for high-frequency power electronic devices [5]. The PdCoO<sub>2</sub> exhibits superior Schottky properties by forming a bilayer with an elemental metal (tandem electrode). The junction between the tandem electrode and β-Ga<sub>2</sub>O<sub>3</sub> has a wide range of Schottky barrier heights that can be fine-tuned by changing the thickness of PdCoO<sub>2</sub> [6]. The interface dipole effect was also found in the junction between β-Ga<sub>2</sub>O<sub>3</sub> and PdCrO<sub>2</sub>, a sister compound of PdCoO<sub>2</sub> [7], suggesting the universal role of surface polarity in these polar oxides.

These results demonstrate that PdCoO<sub>2</sub> and related metallic delafossites are a fascinating class

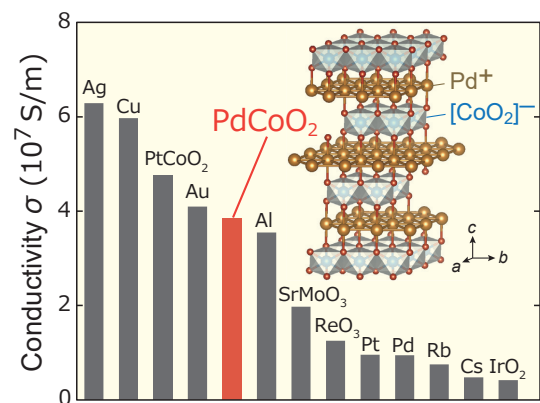


Fig. 1 Electrical conductivity of PdCoO<sub>2</sub> and various metals at room temperature. Inset: the crystal structure of PdCoO<sub>2</sub>. The ionic layers of Pd<sup>+</sup> and [CoO<sub>2</sub>]<sup>-</sup> are indicated.

of materials for basic physics and various applications. We will continue to explore exotic phenomena and functions in the heterostructures of metallic delafossites, which have high-mobility electrons and surface polarity in their simple (and beautiful) alternating layered crystal structures.

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Keywords: oxide, thin films, devices

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